IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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In re Application of Examiner: Belyaev

Belouet et al. Group Art Unit: 1791

Serial No.: 10/584,698

Filed: May 25, 2007

For: A DEVICE FOR DEPOSITING S LAYER OF POLYCRYSTALLINE SILICON

ON A SUPPORT

AMENDMENT

SUBMITTED VIA EFS WEB

Commissioner for Patents PO Box 1450 Alexandria, VA 22313-1450

SIR:

In connection with the above-referenced application, please enter the following amendments and remarks in response to the Office Action dated October 14, 2009.

Amendments to the Claims are reflected in the listing of Claims which begins on page 2 of this paper.

Remarks begin on page 6 of this paper.